

Korean International Semiconductor Conference & Exhibition on Manufacturing Technology 2025

KISM 2025 BUSAN

Re:Innovation of Semiconductor Manufacturing for AI Ecosystem

[WeE3] Reliabili	y and Integ	gration Challeng	ges in Advanced Pac	kaging
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Session Date November 12 (Wed.), 2025

Session Time 16:05-17:35

Session Room Room E (Sicily Room, 1F)

[WeE3-1] [Invited] 16:05-16:25

Emerging CMP Solutions for Next Generation Advanced Packaging Process

Jae-Dong Lee, Eunok Kim, Yeongjung Kim, Hyungoo Kong, Jae Hak Lee, and Seung Mahn Lee (KCTech, Korea)

[WeE3-2] [Invited] 16:25-16:55

Wet Cleaning Process Issues with Memory Device Scaling

Young-Hoo Kim, Pyojin Jeon, Junho Yun, Junho Lee, Yongwook Lee, Gunshik Yun, Sunghyun Park, Jungwan Han, Ji-Hoon Jeong, Tae-Hong Kim, Woogwan Shim, Sungyong Park, and Hyosan Lee (Samsung Electronics Co., Ltd., Korea)

[WeE3-3] 16:55-17:15

Mitigating Galvanic Corrosion in Cu/Ru Interfaces through Selective Surface Interactions for Ru Barrier Metal CMP

Ganggyu Lee, Sumin Hong, Giha Lee, Byungjoon Kim, Taeseup Song, and Ungyu Paik (Hanyang Univ., Korea)

[WeE3-4] 17:15-17:35

Si-Wafer Polishing Rate Enhancement by Amine Functional Group as Hydrolysis Reaction Accelerator

Min-Uk Jeon, Pil-Su Kim, Se-Hui Lee, Hye-Min Lee, Su-Bin Kim, Ji-Hye Shin (Hanyang Univ., Korea), Jin-Hyung Park (ENF Technology. Co., Ltd., Korea), Kyoo-Chul Cho (Hanyang Univ., Korea), Tae-Dong Kim (Hannam Univ., Korea), Jin-Sub Park, and Jea-Gun Park (Hanyang Univ., Korea)